Supporting material

Exploring the Relative Bending Status of a CVD Graphene Monolayer with Gap-Plasmon

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Figure S1. (a) Experimental setup and sample structure. The illumination and detection are carried out in the epi-direction using up-right microscope system. (b) Atomic Force Microscope (AFM) image of Au NP-graphene-Au film system

Figure S1(a) shows the experimental configuration. A gold thin-film with thickness of 10 nm is formed on a cleaned glass substrate by thermal evaporation. The separate Atomic Force Microscope (AFM) measurement found the typical rms roughness of the film to be less than 0.2 nm. We employ a dry-transfer process for the graphene film using a soft substrate such as polymethyl methacrylate (PMMA) stamp.³³ Here we first attach the PMMA stamp to the CVD-grown graphene film on the Cu substrate. The Cu substrate can be etched away using FeCl₃, leaving the adhered graphene film on the PMMA substrate. After cleaning with DI water, we can transfer a FLG film to the Au substrate. After transferring graphene onto the Au film, a drop of Au colloidal nanoparticle solution (nominal diameter ~200 nm, BB International) is applied (~15 μ L) onto the graphene-Au film, followed by rinsing and air-drying at ambient temperature. Figure S1(b) shows the AFM image of Au NP-graphene-Au film system.



Figure S2. (a) SERS spectra obtained from #1 to #7 domains shown in the inset image. Bright circle type shows the SERS image gated at LBM peak.(inset) Note that the only LBM peak is started to emerge abruptly at low-wavenumber region. ($< 700 \text{ cm}^{-1}$)

Figure S2 shows the SERS spectra of FLG along with the numbered axis from inset image. The number of graphene layer may be deduced nearly 5 layers considering the LBM peak position.³⁵ From #1 to #7, the Raman intensities of each phonon mode are enhanced with the accompanied background as approaching to the center of the junction. The #1 point, where uttermost region from Au NP, exhibits narrowly weak 2D and G mode Raman signal. By approaching the target point to closer to the center of Au NP, Raman signal enhancement of 2D, G and D modes is clearly observed due to electromagnetic (EM) enhancement effect. Specifically, the Raman mode, observed at ~150 cm⁻¹ with Full Width at Half Maximum (FWHM) of ~16 cm⁻¹ is newly observed with very high signal-to-noise ratio, which is not observed at conventional Raman spectrum at bare Au film or SiO₂/Si substrate as well. Previously, the graphene Raman peak at low-wavenumber (< 700 cm⁻¹) was studied at a few groups. Chun Hung Lui et al reported a comprehensive determination of the different LBM frequencies for FLG by means of the two-phonon overtone spectra observed in doubly resonant Raman spectroscopy from two to 20 layers over the spectral range of $80 \sim 300 \text{ cm}^{-1.34}$ In particular, the Raman peak at ~ 150 cm⁻¹ at Figure 4 from ref 35 maybe coincided with our Raman peak at ~ 150 cm⁻¹. Previously, we could assign that the low-wavenumber SERS peaks were associated with the out-ofplane layer breathing mode (LBM) at the near zone center region and we could interpret that the strongly observed SERS signal at $\sim 150 \text{ cm}^{-1}$ is ascribed to the LBM of the a FLG.^{26,34}



Figure S3. Lateral approach profiles of each phonon mode of FLG from #1 to #7. Dramatic enhancement of SERS intensity from LBM is observed rather than G and 2D modes.

Figure S3 shows the SERS intensity approach profiles of each phonon modes of the FLG from #1 to #7 direction. Interestingly, it is clearly distinguished that approach profiles are phonon mode-dependent. First of all, the enhancement of the SERS intensities of 2D and G modes along with the #1 to #7 is not significantly enhanced, while the LBM mode shows the relatively large increase of SERS intensities along with the #1 to #7 direction than the 2D and G modes. The G mode is associated with the doubly degenerate (iTO and LO) phonon mode (E_{2g} symmetry) at the Brillouin zone center and the vibration is *in-plane* direction. On the other hand, LBM is one of the representative *out-of-plane* phonon modes. It gives us

that the observed LBM mode is considerably and sensitively influenced by the local z-field formed at the near-center of the Au NP-Au film junction in terms of coinciding between zpolarized incident and the LBM phonon axis, leading to dramatic Raman enhancement. However, the G and 2D modes whose vibration is in-plane do not significantly be affected by the incident z-field relatively. Note that D mode shows the moderate SERS enhancement feature. It is well-known that SP³-type defects are generally displayed as D mode.¹⁰ Not only for in-plane but also out-of-plane defect such as functional group bonding maybe partially influential, resulting in the moderate SERS enhancement of D mode along the zaxis.³⁴ The SERS enhancement factor per area (nm²) at Au NP-Au film can be calculated by dividing I(#7) to I(#1)considering the corresponded each focused spot area. The focused area at I(#7) is defined as $\sim \lambda_{exe}/2NA$ while that of the I(#1) can be obtained approximately by the electro-dynamic simulation via Finite Different Time Domain (FDTD) method.35 Table S1 shows the summarized mode-dependent SERS enhancement factor (EF) per area.

 Table S1. Mode-dependent SERS enhancement factor per area (nm²)

	LBM	G	2D
$EF(/nm^2)$	~3.0×103	~5.5×10²	~6.4×10 ²

To conclude, we present that Raman enhancement of a FLG of each phonon mode sandwiched at Au NPs-Au film junctions is different and can be ascribed to the different incident polarization. Closer to the center of the junction, LBM shows dramatic Raman enhancement than the 2D and G modes in terms of coinciding between the z-polarized incident field formed at Au NP-Au film junction and the LBM phonon axis, which can also be quantified that the SERS enhancement factor of the LBM is more than ~ 5.5 times larger than that of the G and 2D modes.

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